

INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

December 10, 2025

IGI Report Number

Description

Shape and Cutting Style

Measurements

LG756515874

LABORATORY GROWN DIAMOND

EMERALD CUT

12.35 X 8.68 X 5.83 MM

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

6.09 CARATS

F

VS 1

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence


EXCELLENT

EXCELLENT

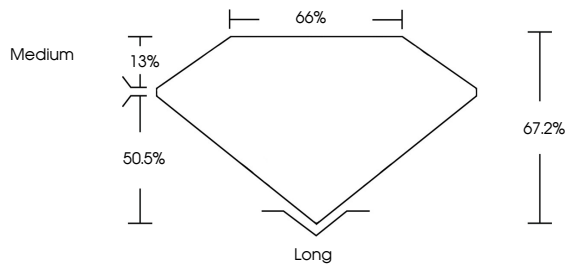
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Inscription(s)

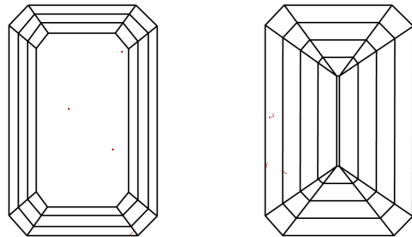
Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

 LG756515874

PROPORTIONS



CLARITY CHARACTERISTICS




KEY TO SYMBOLS

Red symbols indicate internal characteristics.

Green symbols indicate external characteristics.

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6.09 CARATS

F

VS 1

ADDITIONAL GRADING INFORMATION

Polish

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
EXCELLENT

EXCELLENT

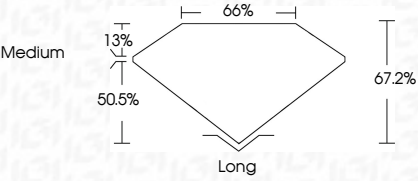
NONE

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PROPORTIONS



IGI



December 10, 2025

IGI Report No LG756515874

EMERALD CUT

12.35 X 8.68 X 5.83 MM

6.09 CARATS

F

VS 1

67.2%

50.5%

Medium

Long

EXCELLENT

EXCELLENT

NONE

 LG756515874

Cutler

Polish

Symmetry

Fluorescence

Inscription(s)

Long

EXCELLENT

EXCELLENT

NONE

 LG756515874

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